

Semiconductor Production

Wet Station

High Quality & Multi-Cleaner

Feature

Application: Silicon Wafer / Compound semiconductor / LCD

Multiple	For development & experimental	[Batch type / Cassette type] Si: 4 ~ 12 inch、Glass: 100 ~ 300mm [Single wafer process] Si: 6 ~ 8 inch、Glass: 100 ~ 300mm Equipment for 300mm (Switching: handling unit)
Production	For multiple kind & small quantity	

Finishing process wet station

